

Direct and pulse current electrodeposition of Ni–W–TiO₂ nanocomposite coatings

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Abstract

Ni–W–TiO₂ nanocomposite coatings have been obtained on mild steel surface by direct current (DC) and pulse current (PC) electrodeposition from Watts bath containing an ammonical citrate complexing agent. The morphology of the coatings was explored by scanning electron microscopy (SEM), atomic force microscopy (AFM) and the composition of the electrodeposits was analyzed by energy dispersive X-ray analysis (EDX). Surface morphology studies revealed that Ni–W alloy surface was covered by long needle like crystals and Ni–W–TiO₂ composite coatings with smaller spherical sized grains. The coated surface contained 25.55% W and 5.55% Ti. XRD studies revealed that (111) plane was predominant in both Ni–W alloy deposits and Ni–W–TiO₂ composite coatings. The patterns of the electrodeposits confirmed only fcc frame work structure. Microhardness values increased with TiO₂ addition in the alloy. The corrosion resistance of Ni–W alloy deposit and TiO₂ incorporated coatings was evaluated by Potentiodynamic polarization studies in 3.5% NaCl solutions. Corrosion current densities decreased with TiO₂ inclusion in the alloy deposit. Electrochemical impedance studies revealed that the charge transfer resistance increased with TiO₂ inclusion in the alloy deposits while the double layer capacitance decreased. The PC composites coatings offer uniform surface, high microhardness and enhanced corrosion resistance than DC composites coatings.

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Keywords: B. Nanocomposites; Pulse electrodeposition; Surface morphology; Microhardness

1. Introduction

Electrodeposited composite coatings exhibited enhanced material properties such as a mechanical, electrochemical and oxidation properties compared to pure metal coatings. Improvement of these properties depended mainly on the size and the percentage of the electrodeposited particles [1]. Pulse plating offers a greater control over the structure and properties of electrodeposits than the conventional direct current plating [2]. Pulse current electrodeposited coatings have higher mechanical and tribological properties compared to direct current electrodeposits [3,4]. The composite coatings of nickel (Ni–Al₂O₃, Ni–SiC and Ni–ZrO₂) have

been prepared and the amount of reinforcement in the coatings increased in the pulse current and pulse reverse current deposition compared to direct current [5]. The effect of pulse frequency, duty cycle and concentration of Si₃N₄ nanoparticles containing a nickel sulfate bath had been discussed [6]. Nano Ni–TiN coating was obtained using ultrasonic electrodeposition [7]. The Ni–Al₂O₃ composite coatings were prepared by DC, PC and PRC electrodeposition methods. The corrosion behavior of these electrodeposits at high temperatures was also investigated [8]. Electrochemical impedance spectroscopy was used to characterize the mechanism involved in the deposition of the nickel–cerium oxide coatings from the chloride baths [9]. The electrodeposition of Ni–SnO₂ composite coatings on steel substrates and the evaluation of mechanical properties had been reported [10]. TiO₂ co-deposition was carried out with Cu and Zn as the metallic components [11–13]. The co-deposition of TiO₂ particles in

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nickel matrix to improve the mechanical and corrosion properties had been investigated [14–19]. The Ni–TiO₂ composite coatings were prepared on steel substrates through electrodeposition and its mechanical properties had been reported [20].

The corrosion studies in 3.5 wt% NaCl solution at pH 3 and 10 for the reverse pulse electrodeposited nanocrystalline Ni–W alloys revealed that the corrosion rates of the alloys have increased with the reduction of grain size in alkaline solutions but decreased with in acidic solutions [21]. Corrosion resistance behavior of nanocrystalline Ni–W alloy coatings were electrodeposited using a direct and pulse current methods [22–26]. Various amounts of TiO₂ incorporation in Ni–P–TiO₂ nanocomposite coatings were electrodeposited on low carbon steel [27]. Direct, pulse and pulse reverse current electrodeposition of Ni–Co–Al₂O₃ composite coatings and the microstructure of the deposits had been discussed [28,29]. TiO₂ incorporation was carried out in Ni–Co alloy matrix. The microstructure and its corrosion property had been reported [30].

Direct current method was used to deposit Ni–W–SiC nanocomposite at high current density ranges from 6 to 18 A/dm² [31]. Ni–W–La₂O₃ coating was also prepared by direct current method. La₂O₃ addition refined the microstructure of Ni–W alloy and provided uniform elemental distribution [32]. CeF₃ was co-deposited with Ni–W alloy by direct current method to improve the tribological properties [33]. Pulse plating was used to incorporate nanosized Al₂O₃ particles in the Ni–W alloy [34]. MoS₂ particles were co-deposited with Ni–W using pulse plating to provide effective lubricative coatings [35]. Pulse current was used to get Ni–W–CNT nanocomposite coatings with more carbon nano tubes and uniform distribution of carbon nano tubes in the coatings [36]. The amount of CeO₂ present in the Ni–W coating and high temperatures tribological performances of the composite coating against molten glass were also investigated [37].

The present communication deals with the direct current and pulse current electrodeposition of Ni–W–TiO₂ nanocomposite coatings obtained from citrate complexed alkaline bath (pH 9). The electrodeposits were characterized for their surface morphology and surface structure using the scanning electron microscopy and XRD. Hardness measurements were also carried out on the electrodeposits.

Corrosion resistance properties were evaluated by using electrochemical measurements in 3.5% NaCl solution at pH 7.

2. Experimental details

Cold rolled mild steel plates were polished with fine grid paper and degreased with trichloroethylene, then cathodically electrocleaned in alkaline solution for 2 min and anodically for 30 s in a solution mixture containing 35 g L^{−1} NaOH and 25 g L^{−1} Na₂CO₃ at 30 °C. They were washed in running water and then dipped in 5% H₂SO₄ solutions for 10 s. The current density applied for cathodic cleaning was 7 A/dm². Open circuit potential of the polished, pre cleaned steel specimens in the plating bath (pH=9) was −540 mV vs SCE. After the application of cathodic current density, the potential of the steel became −1100 mV vs SCE.

Pulse and direct current electrodeposition was carried out using a Myriad Bipolar pulsed power supply (Shruthi Enterprises, Bangalore) was employed. Thus prepared mild steel plates of size 3 × 2.5 × 0.05 cm were used as cathodes. The pure nickel plate of size 4 × 2.5 × 0.4 cm was used as anode. All the chemicals used were of AnalaR Grade. Table 1 summarizes the suppliers of the chemicals and conditions of the electrodeposition. The titanium oxide (TiO₂) was crystalline and anatase with structure. The particle size of titanium dioxide was 200–500 nm. The hardness of the electrodeposits was measured by using MHG Everyone Hardness Tester (Hong Kong). The microhardness of the deposit in kg mm^{−2} was determined by using the formula

$$H_v = 1854 \times L/d^2 \quad (1)$$

where L is the load applied in g and d the diagonal of the indentation (μm). The load applied was 50 g. Scanning electron microscope (SEM) (HITACHI S-570, Japan) was used to characterize the surface morphology of the composite coatings. For these studies, the electrodeposited panels were cut in to 1 cm × 1 cm size, cold mounted, examined and photographed. The deposited surface was subjected to EDAX (Energy Dispersive X-ray analysis) for the determination of chemical composition of the deposits. The crystalline structure of the plated substrate was identified by X-ray diffraction using Brooker D8 advance X-ray diffractometer operated with Cu K α radiation (nickel filtered) was used at a rating of

Table 1
Composition and conditions of plating bath.

Chemicals	Source	Composition	Plating parameters
Nickel sulfate	Sigma-Aldrich	0.15 M	Pulse peak c.d. 1.5 Adm ^{−2}
Sodium tungstate	Sigma-Aldrich	0.15 M	pH 9
Tri-ammonium citrate (TAC)	Sigma-Aldrich	0.30 M	Time 40 min
Ammonium chloride	SRL	0.20 M	Temperature 70 °C
Dimethyl sulphoxide (DMSO)	SRL	0.06 M	Constant stirring
Sodium lauryl sulfate (SLS)	Sigma-Aldrich	0.80 gL ^{−1}	Pulse Duty Cycle
2-Butyne 1,4-diol (BD)	SRL	50 m gL ^{−1}	On time: 40 ms
Anatase-(TiO ₂)- 200–500 nm	Sigma-Aldrich	0–15 gL ^{−1}	Off time: 30 ms

40 KV, 20 mA. The scan rate was 0.05 °C per step and the measuring time 15/step. The crystallite size was calculated by using the Scherrer equation [38].

$$D = \frac{0.9\lambda}{\beta \cos\theta} \quad (2)$$

where D is the crystallite size, λ is the incident radiation (1.5418 Å), β is the corrected peak width at half-maximum intensity and θ is the angular position. Electrochemical measurements were carried out using a three electrodes cell assembly. Electrodeposit of 1 cm² exposed area was used as a working electrode. A rectangular platinum foil and a saturated calomel electrode were used as auxiliary and reference electrodes respectively. The test solution was 3.5% NaCl kept at 30 °C. Electrochemical polarization studies were carried out by using Eco-chemie-Potentiostat galvanostat (Auto lab). Electrochemical impedance measurements were done on the electrodeposits after they attained steady corrosion potential. The impedance measurements were made in the frequency range of 10 Kc/s–10 mc/s with a sinusoidal perturbation of 10 mV.

3. Results and discussion

3.1. X-ray diffraction studies

X-ray diffraction patterns for Ni–W alloy as well as Ni–W–TiO₂ nanocomposites are shown in Fig. 1. These patterns revealed crystalline fcc structure of Ni–W alloy with predominant planes (111), (200) and (220). JCPDS standards (65-4828) have confirmed the patterns. The crystallite sizes of Ni–W and Ni–W–TiO₂ (DC, PC) nanocomposites were calculated using Scherrer equation. The crystallite sizes of (111) plane of electrodeposited Ni–W, Ni–W–TiO₂ (DC) and Ni–W–TiO₂ (PC) were found to be 102 nm, 80 nm and 72 nm respectively. Pulse electrodeposits had smaller crystals compared to direct current electrodeposited Ni–W–TiO₂

nanocomposite and Ni–W alloy coatings. The addition of TiO₂ decreased the crystallite sizes.

In an earlier study [23] the appearance of peaks at 51°, 60° and 90°, 2θ values in the diffractograms were related to (111), (200) and (220) planes of Ni₁₇W₃ alloy in the Ni–W electrodeposits. Only noticeable differences can be observed in the intensities of (111), (200) and (220) peaks for Ni–W–TiO₂ nanocomposite. The (111) peak intensity was greater than other planes suggesting the predominant (111) texture. The crystallite sizes were of the order of nm. The development of this texture was associated with the preferred growth along (111) orientation because of the lower strain associated

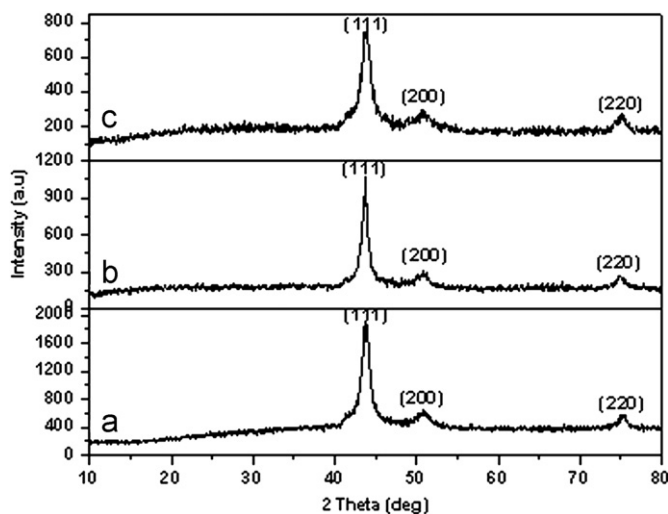


Fig. 1. XRD Patterns observed for: (a) Ni–W alloy deposit (b) Ni–W–TiO₂ (DC) composite and (c) Ni–W–TiO₂ (PC) composite.

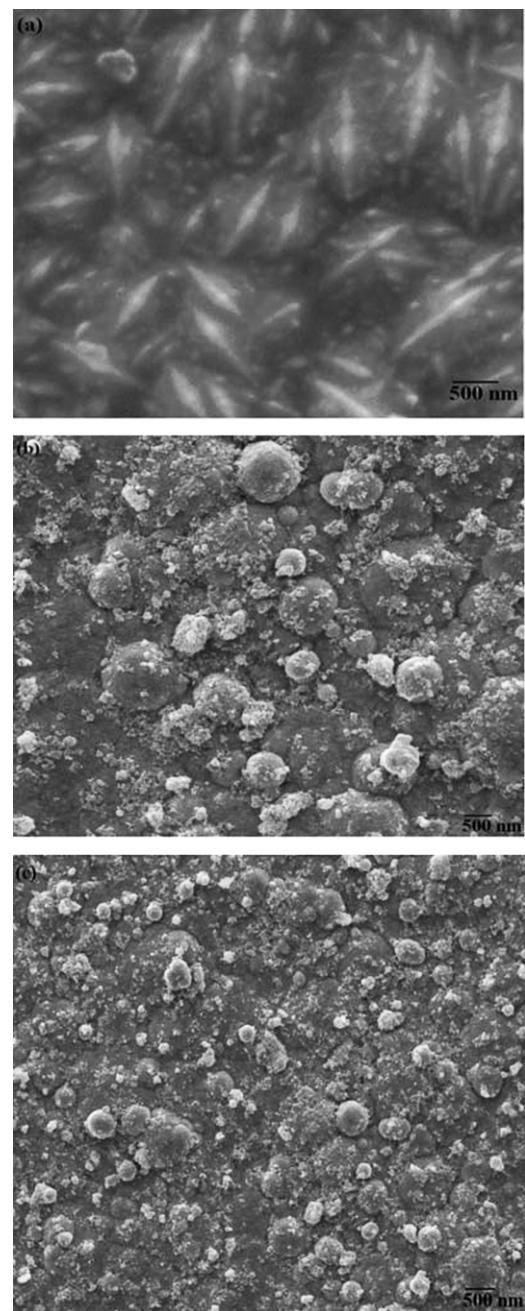


Fig. 2. SEM for electro: (a) deposit A (b) deposit D by DC method (C) deposit D by PC method.

in this direction. Broadened Bragg peaks were seen in the nanocomposites compared to Ni–W alloy deposit. This broadening was increased with addition of TiO₂ in the Ni–W alloy deposit. This is due to the reduction in crystallite size with TiO₂ addition. The formation of non-crystalline structure was not favoured as seen from the appearance of well-defined sharp peaks.

3.2. SEM and EDAX measurements

Surface morphologies of electrodeposits obtained under various conditions are shown in Fig. 2a–c. The needle shaped grain was seen on the surface of Ni–W alloy. Ni–W–TiO₂ nanocomposite surface obtained under DC and PC conditions were found to have smaller spherical shape grains. These suggest that TiO₂ particles were uniformly distributed in the alloy matrix. The composite deposits obtained from PC method exhibited smooth and smaller spherical shape grains compared to the nanocomposite surface obtained by the DC method. The EDAX spectra of the electrodeposits are shown in Fig. 3a–c. The EDAX analysis gives the % of elements present in the Ni–W–TiO₂ nanocomposite coatings (Table 2). The EDAX analysis reveals that oxygen content is less than that of corresponding TiO₂. Perhaps some of the surface TiO₂ particles might have undergone “catalytic reduction” to Ti by adsorbed

nascent H₂ formed during electrodeposition. However, bulk deposit contained TiO₂ particle.

3.3. AFM measurements

Fig. 4a–c shows that the surface morphologies of electrodeposited Ni–W alloy and Ni–W–TiO₂ nanocomposite coatings were prepared by DC and PC methods. The pulse current electrodeposited Ni–W–TiO₂ nanocomposite coating surface had much smaller particle size. The co-deposited TiO₂ particles were uniformly distributed over the Ni–W alloy matrix. The presence of TiO₂ decreased the size of particles.

Table 2
EDAX analysis of Ni–W and Ni–W–TiO₂ nanocomposite coating.

Deposit	Elements	Amount of nanocomposite (%) ± 0.1
A	Ni	71.4
	W	28.5
D-DC	Ni	68.60
	W	26.45
	Ti	3.26
	O	1.58
D-PC	Ni	67.4
	W	25.01
	Ti	5.55
	O	1.88

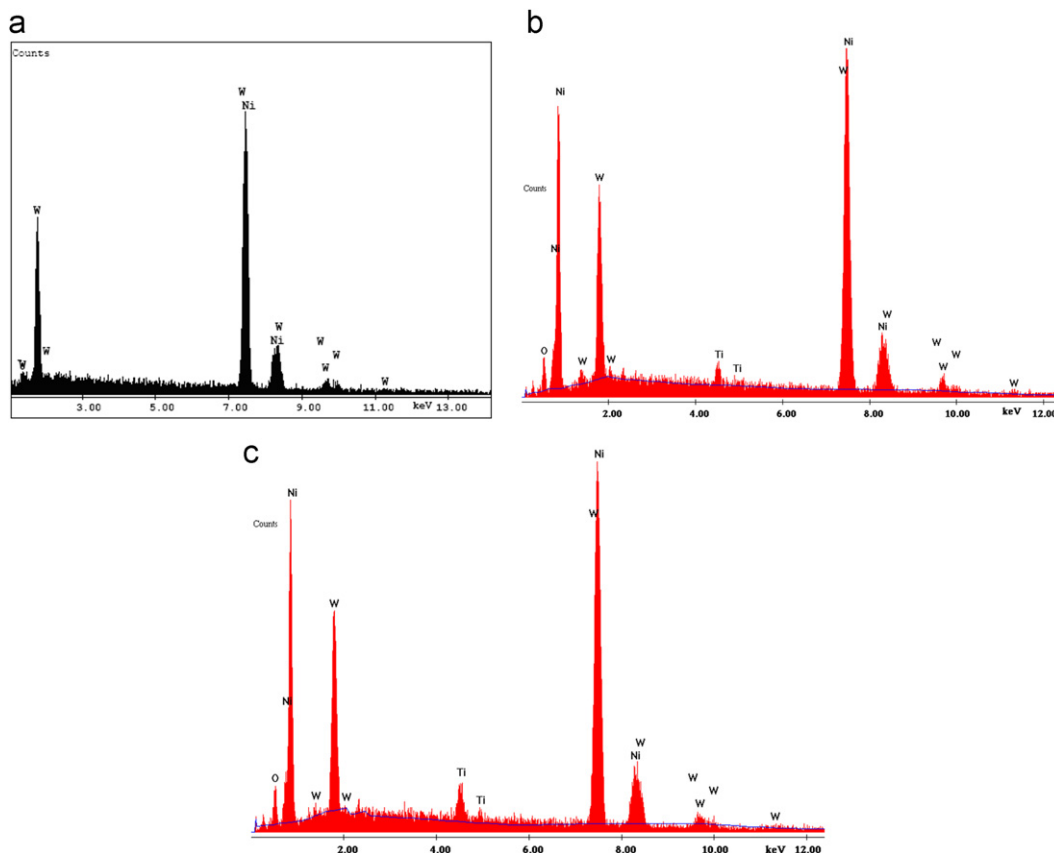


Fig. 3. EDAX spectrum for: (a) deposit A (b) deposit D by DC method (C) deposit D by PC method.

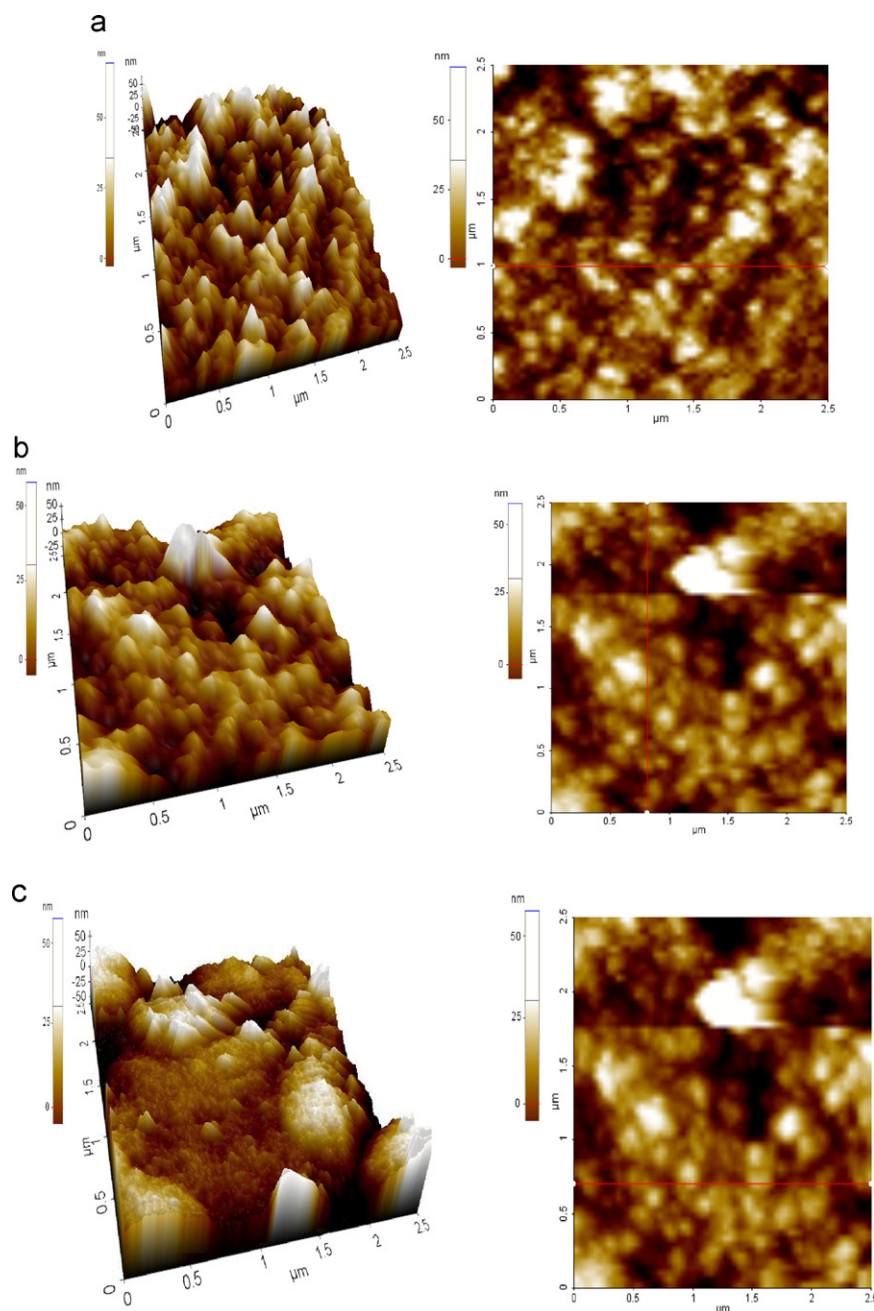


Fig. 4. (a) AFM images of Ni–W alloy deposit. (b) AFM images of Ni–W–TiO₂ deposit by DC method. (c) AFM images of Ni–W–TiO₂ deposit by PC method.

3.4. Microhardness test

Fig. 5 presents the microhardness values for various electrodeposits. Incorporation of TiO₂ particles in the alloy enhanced the microhardness. PC deposits offer enhanced microhardness compared to DC deposit. The microhardness values were varied from 467 to 686 Hv. The amount of TiO₂ present in the coating contributed to its higher hardness. The incorporation of TiO₂ had taken place on the metal layer by adsorption as suggested by Guglielmi's two-step adsorption model [39,40]. Increase in microhardness is due to (a) dispersive strengthening effect of TiO₂ (b) nanoparticles in the composite coatings blocking the dislocation motion and

the grain boundary sliding of the matrix and (c) nanoparticles in the coatings restricted the growth of crystalline bulk in the process of electrodeposition. The PC composite had a finer grain size which caused lower porosity of the coating and greater compact structure.

3.5. Electrochemical characterizations

Corrosion resistances of the electrodeposits were evaluated in 3.5% NaCl solution by electrochemical methods. Fig. 6 presents the polarization curves obtained from potentiodynamic polarization method for various DC deposits. The linear segments of the anodic and cathodic

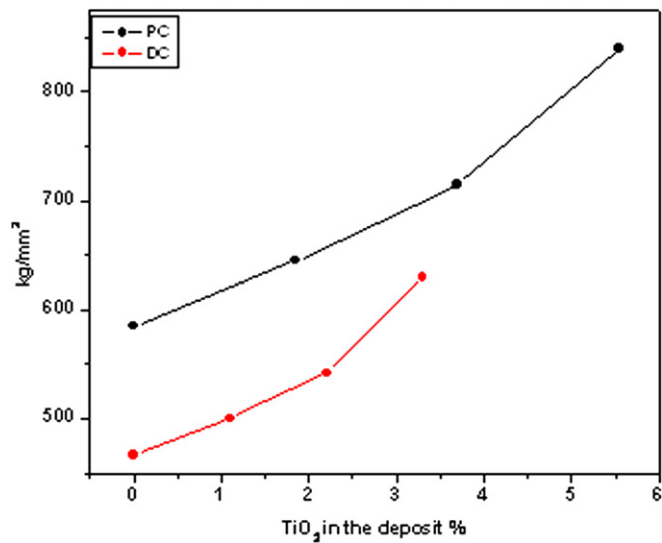


Fig. 5. Effect of the co-deposited TiO₂ on the microhardness of Ni–W–TiO₂ nanocomposite coatings.

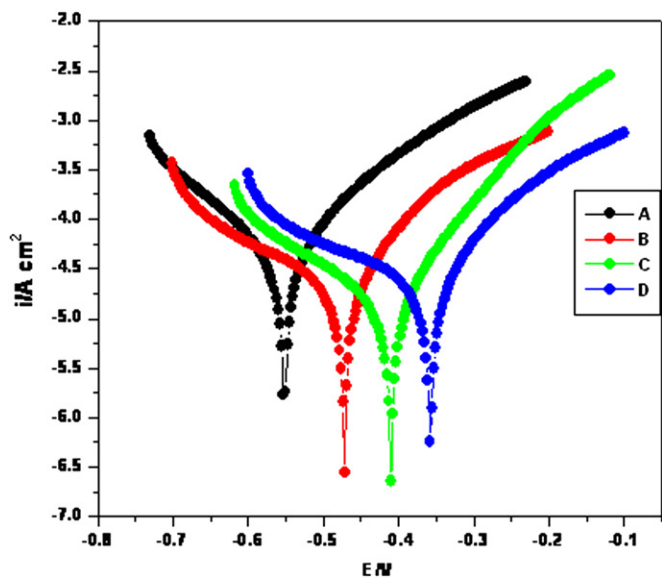


Fig. 6. Potentiodynamic polarization curves for Ni–W alloy deposit and for various amounts of TiO₂ incorporated in to Ni–W alloy deposit by DC Method.

Table 3
Parameters derived from potentiodynamic polarization curves for Ni–W deposit and Ni–W–TiO₂ nanocomposite coatings obtained using DC Method.

Deposit	TiO ₂ in the deposit (wt%)	E_{corr} vs SCE (mV)	b_a (mV decade ⁻¹)	b_c (mV decade ⁻¹)	i_{corr} (μA cm ⁻²)
A	0	–550	125	98	16.8
B	1.1	–471	96	103	13.7
C	2.2	–410	109	98	7.5
D	3.3	–358	121	73	5.4

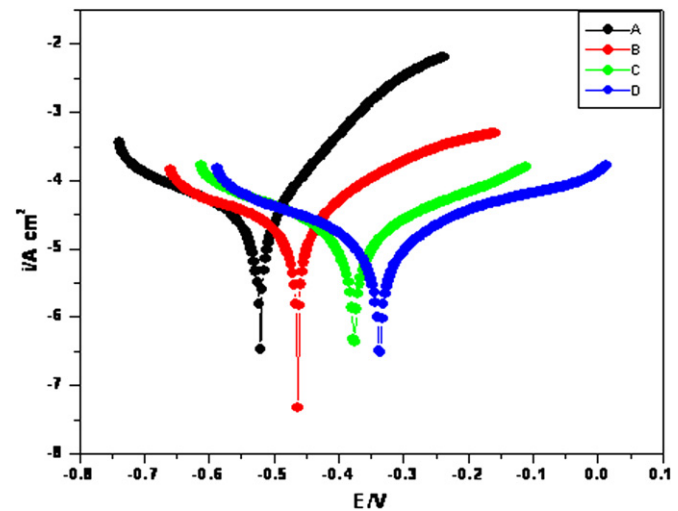


Fig. 7. Potentiodynamic polarization curves for Ni–W alloy deposit and for various amounts of TiO₂ incorporated in to Ni–W alloy deposit by PC Method.

Table 4
Parameters derived from potentiodynamic polarization curves for Ni–W deposit and Ni–W–TiO₂ nanocomposite coatings obtained using PC Method.

Deposit	TiO ₂ in the deposit (wt%)	E_{corr} vs SCE (mV)	b_a (mV decade ⁻¹)	b_c (mV decade ⁻¹)	i_{corr} (μA cm ⁻²)
A	0	–520	134	95	15.3
B	1.9	–463	63	113	7.5
C	3.7	–375	78	104	6.5
D	5.6	–335	62	73	3.2

curves were extrapolated to corrosion potential to calculate the corrosion current densities. The slopes of these linear segments were used to calculate Tafel slopes. Corrosion current density values decreased with the incorporation of TiO₂ (Table 3). Fig. 7 presents the potentiodynamic polarization curves obtained for various PC deposits. Corrosion current density values decreased with TiO₂ incorporation (Table 4).

The EIS spectra revealed the impedance information for the deposits exposed in corrosive solutions. Fig. 8 presents the Nyquist plots for Ni–W alloy deposit and Ni–W–TiO₂ nanocomposite coatings prepared by DC method. Charge transfer (R_{ct}) and double layer capacitance (C_{dl}) values were increased and decreased with TiO₂ incorporation respectively (Table 5). The Nyquist plots obtained for various deposits prepared by PC method are shown in Fig. 9. All the composite coatings offered increased R_{ct} values and decreased C_{dl} values with TiO₂ incorporation (Table 6). From the electrochemical theory of corrosion, corrosion current densities are inversely proportional to charge transfer resistance. Stern–Geary equation [41] relates

$$i_{\text{corr}} = \frac{1}{2.303 R_{\text{ct}}} \left[\frac{b_a b_c}{b_a + b_c} \right]$$

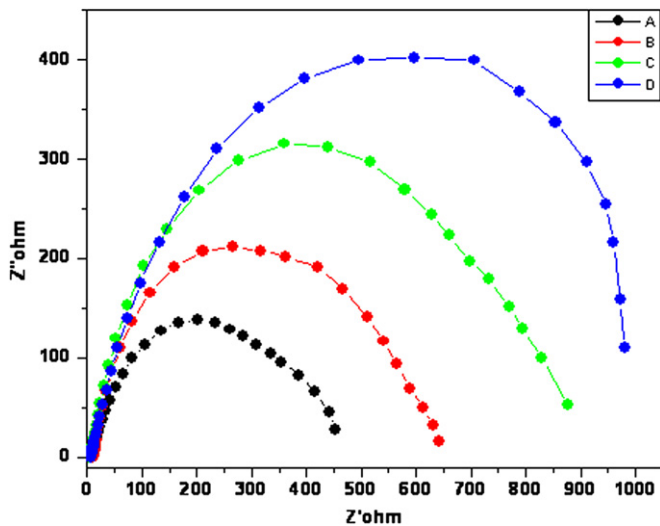


Fig. 8. Nyquist plots (Z'' vs Z') obtained for Ni–W alloy deposit and for various amounts of TiO_2 incorporated in to Ni–W alloy deposit by DC Method.

Table 5

Parameters derived from electrochemical impedance spectrum of Ni–W deposit and Ni–W– TiO_2 nanocomposite coatings obtained using DC Method.

Deposit	TiO_2 in the deposit (wt%)	R_{ct} ($\Omega \text{ cm}^2$)	C_{dl} ($\mu\text{F cm}^{-2}$)
A	0	454	124.90
B	1.1	643	88.44
C	2.2	877	60.52
D	3.3	980	56.02

Table 6

Parameters derived from electrochemical impedance spectrum of Ni–W deposit and Ni–W– TiO_2 nanocomposite coatings obtained using PC Method.

Deposit	TiO_2 in the deposit (wt%)	R_{ct} ($\Omega \text{ cm}^2$)	C_{dl} ($\mu\text{F cm}^{-2}$)
A	0	557	103.21
B	1.9	726	78.33
C	3.7	957	55.46
D	5.6	1032	47.24

where, i_{corr} is the corrosive current density. b_a and b_c are the respective anodic and cathodic Tafel slopes. R_{ct} is charge transfer resistance. In otherwords, $i_{corr} = (K/R_{ct})$. Incorporation of TiO_2 increased R_{ct} values suggesting decrease in corrosion current density values (i_{corr}).

Corrosion of electrodeposits in 3.5% NaCl solution involved electrochemical reactions. Usually noble metal coatings offer a barrier protection to steel [42]. In the present study, Ni–W alloy deposit was found to contain Ni_{17}W_3 intermetallic phase. This phase was nobler than nickel. Nickel dissolved from the alloy matrix by galvanic action. Ni–W– TiO_2 composite surface was found to be smooth and covered by smaller spherical crystallites. Thus

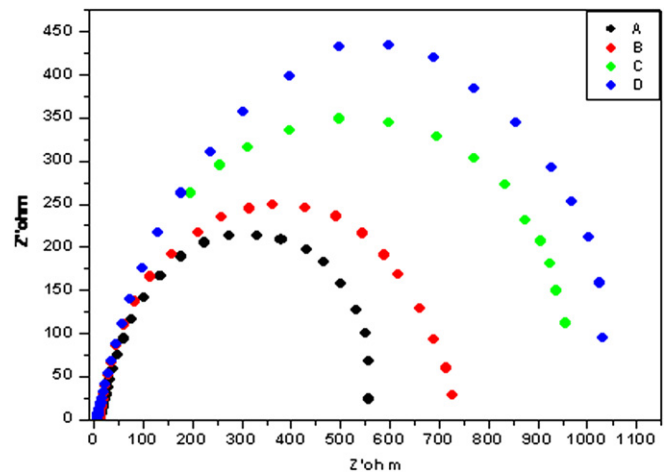


Fig. 9. Nyquist plots (Z'' vs Z') obtained for Ni–W alloy deposit and for various amounts of TiO_2 incorporated in to Ni–W alloy deposit by PC Method.

TiO_2 incorporation prevented the dissolution of nickel by adsorbing on the anodic sites.

The observed semicircle in the Nyquist plots for both DC and PC electrodeposits suggested a simple RC circuit. The addition of TiO_2 in the deposit decreased the capacitance of the double layer values. Pulse current deposits had smaller crystallites and provided larger surface area. It resulted in decrease of double layer capacitance compared to those obtained for DC deposits.

4. Conclusions

Ni–W alloy and Ni–W– TiO_2 nanocomposite coatings on mild steel were prepared by pulse current electrodeposition. Thus prepared nanocomposite coating was compared with those prepared by direct current electrodeposition. Ni–W alloy coating surface was found to be covered by long needle like crystals while Ni–W– TiO_2 composites coating surface had smaller spherical grains. Incorporation of TiO_2 particles in Ni–W alloy coating increased the microhardness values. Ni–W alloy deposit was found to have Ni_{17}W_3 intermetallic phase which was nobler than nickel. Dissolution of nickel was hindered by the incorporation TiO_2 in the Ni–W alloy deposit. The pulse current electrodeposited nanocomposite coatings had enhanced corrosion resistance compared to those of direct current electrodeposition.

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